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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant

Manfred FRIEDRICH, et al.

Serial No.

10/655,896

Filed

September 4, 2003

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Group Art Unit

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Examiner

UNKNOWN

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C. Bruce Hamburg

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Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT

Sir:

Submitted herewith is an Information Disclosure Citation having appended thereto the European Search Report from the counterpart European patent application, which search report indicates the degree of relevance of the documents cited therein. Copies of those documents are not provided herewith because the U.S. Patent and Trademark Office already has them.

F-7904 Ser. No. 10/655,896

I hereby certify that each item of information contained in the Information

Disclosure Statement was first cited in any communication from a foreign Patent

Office in a counterpart foreign application not more than three months prior to the filing of this statement.

Respectfully submitted,

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